

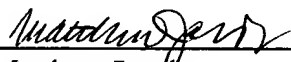
REMARKS

The above amendment is presented to clarify that the weight basis of component (E) is on the weight on the photosensitive resin composition as solids, thereby excluding the possibility that the amount of component (E) could be based on the total weight of the composition including liquids (solvents). See the response of March 7, 2002, e.g. at page 5, *et seq.*, in this regard.

Favorable action is now requested.

Respectfully submitted,

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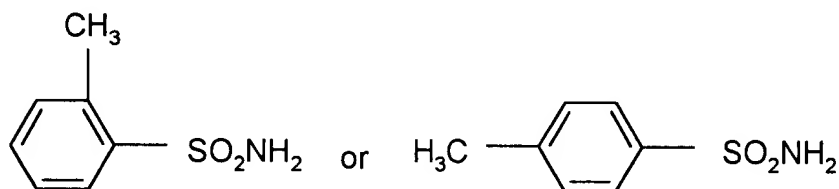
VERSION WITH MARKINGS TO SHOW CHANGES MADE

IN THE CLAIMS:

Claim 1 has been twice amended as follows:

1. (Twice Amended) A negative-working photosensitive composition comprising:

- (A) a film-forming polymer
- (B) an unsaturated compound having a radical polymerizable ethylenic double bond,
- (C) a photopolymerization initiator,
- (D) a thermal polymerization inhibitor, and
- (E) at least one member selected from compounds represented by the following formula:



in an amount of 1.0 - 2.0 wt% based on the weight of the photosensitive resin composition (as solids).

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